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(12) **United States Design Patent** (10) **Patent No.:** **US D458,993 S**
Kopacko et al. (45) **Date of Patent:** **** Jun. 18, 2002**

(54) **NASAL MASK**

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(73) Assignee: **Respironics, Inc.**, Pittsburgh, PA (US)

(**) Term: **14 Years**

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Related U.S. Application Data

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(51) **LOC (7) Cl.** **29-02**

(52) **U.S. Cl.** **D24/110.1**

(58) **Field of Search** D24/110.1, 110.4, D24/110.5, 164; 128/207.11, 207.13, 207.17, 206.24, 206.25, 205.25, 207.18, 204.18, 206.26

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(57) **CLAIM**

The ornamental design for a nasal mask, as shown and described.

DESCRIPTION

FIG. 1 is a front perspective view of a nasal mask showing our new design;

FIG. 2 is another perspective view thereof, taken from the rear;

FIG. 3 is a front elevational view thereof;

FIG. 4 is a right side elevational view thereof, the left side elevational view being a similar thereto;

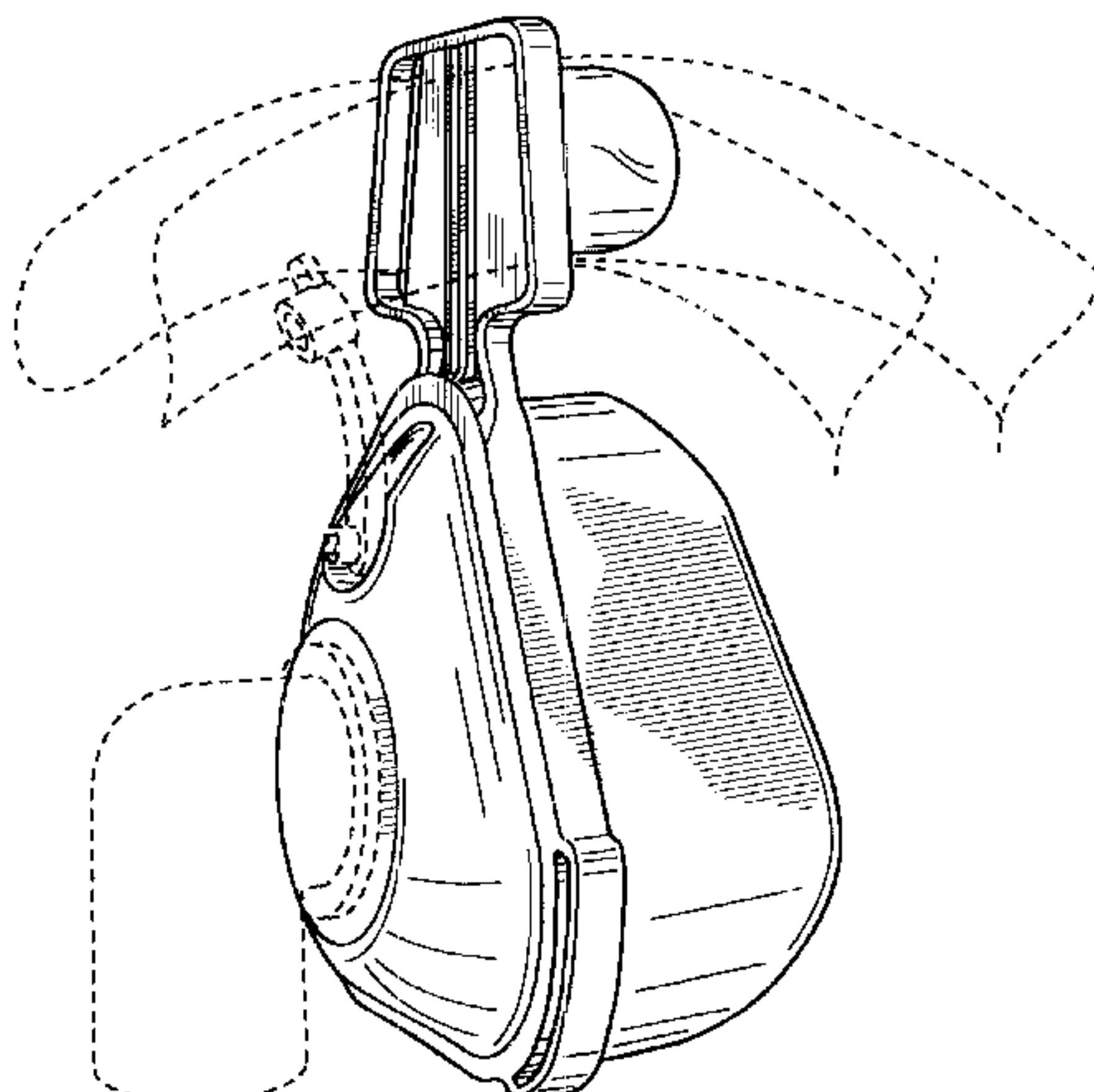
FIG. 5 is a rear elevational view thereof;

FIG. 6 is a top plan view thereof; and,

FIG. 7 is a bottom plan view thereof.

The portions drawn in broken lines are shown for illustrative purposes only and do not form part of the claimed design.

1 Claim, 6 Drawing Sheets





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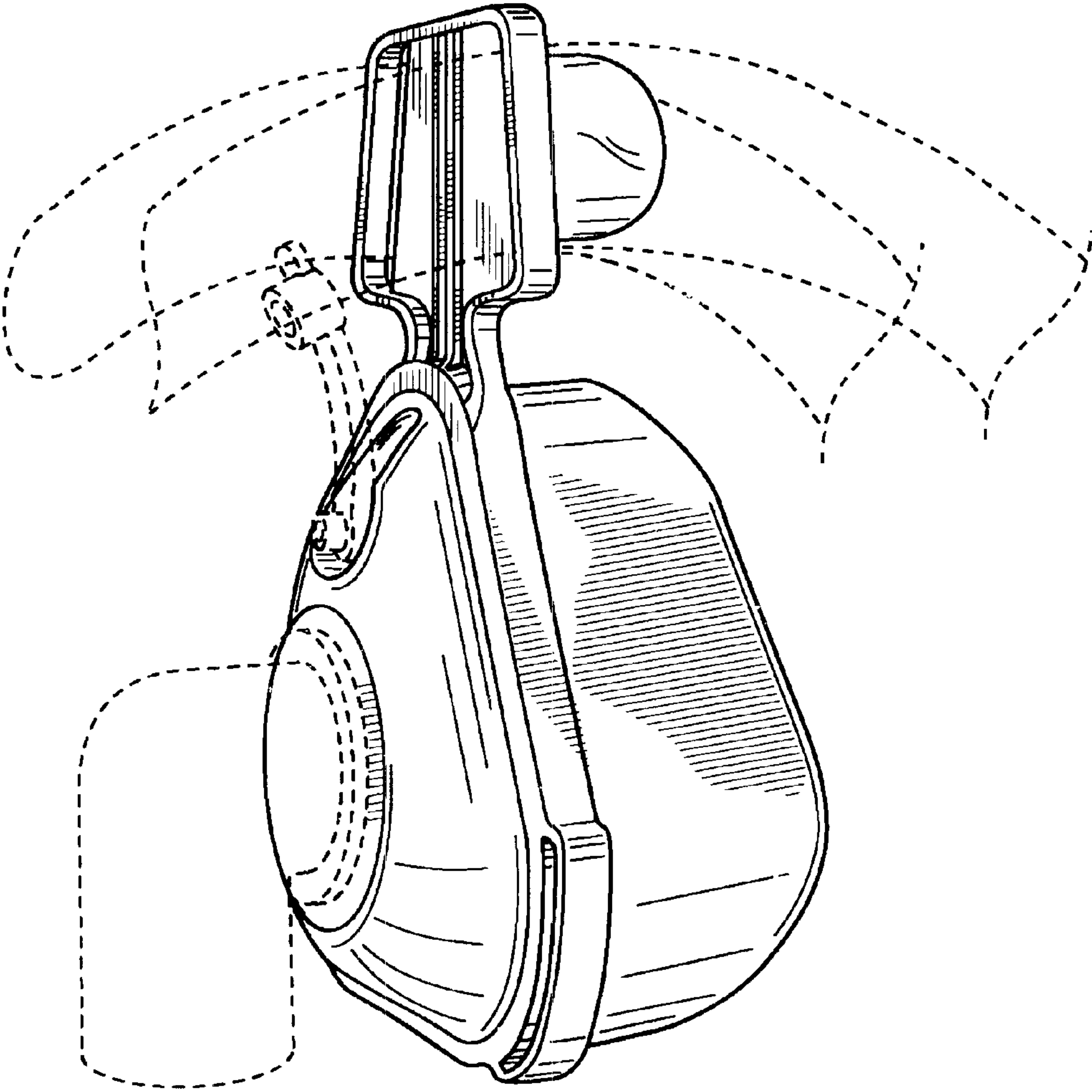


FIG. 1

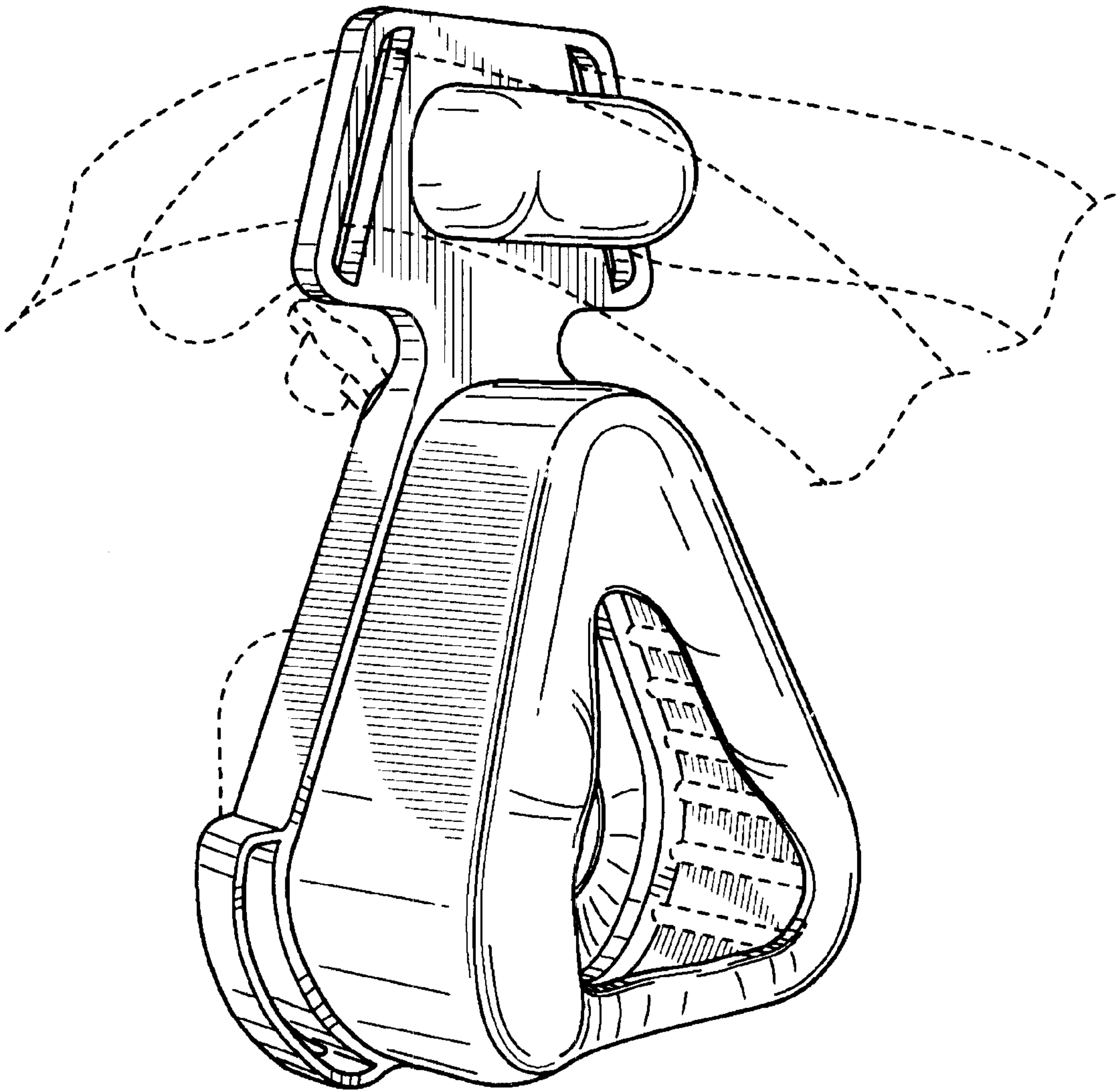


FIG. 2

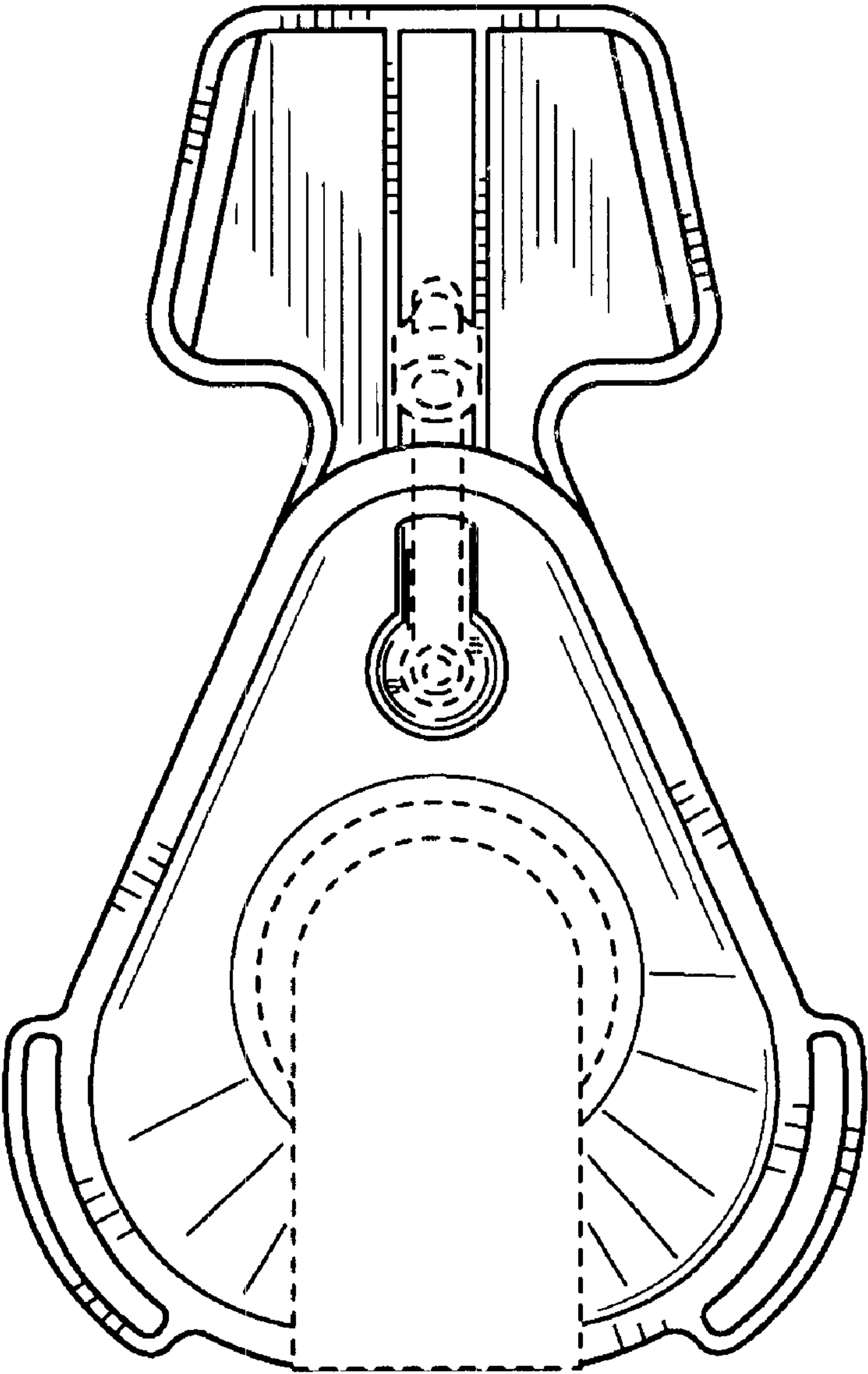


FIG. 3

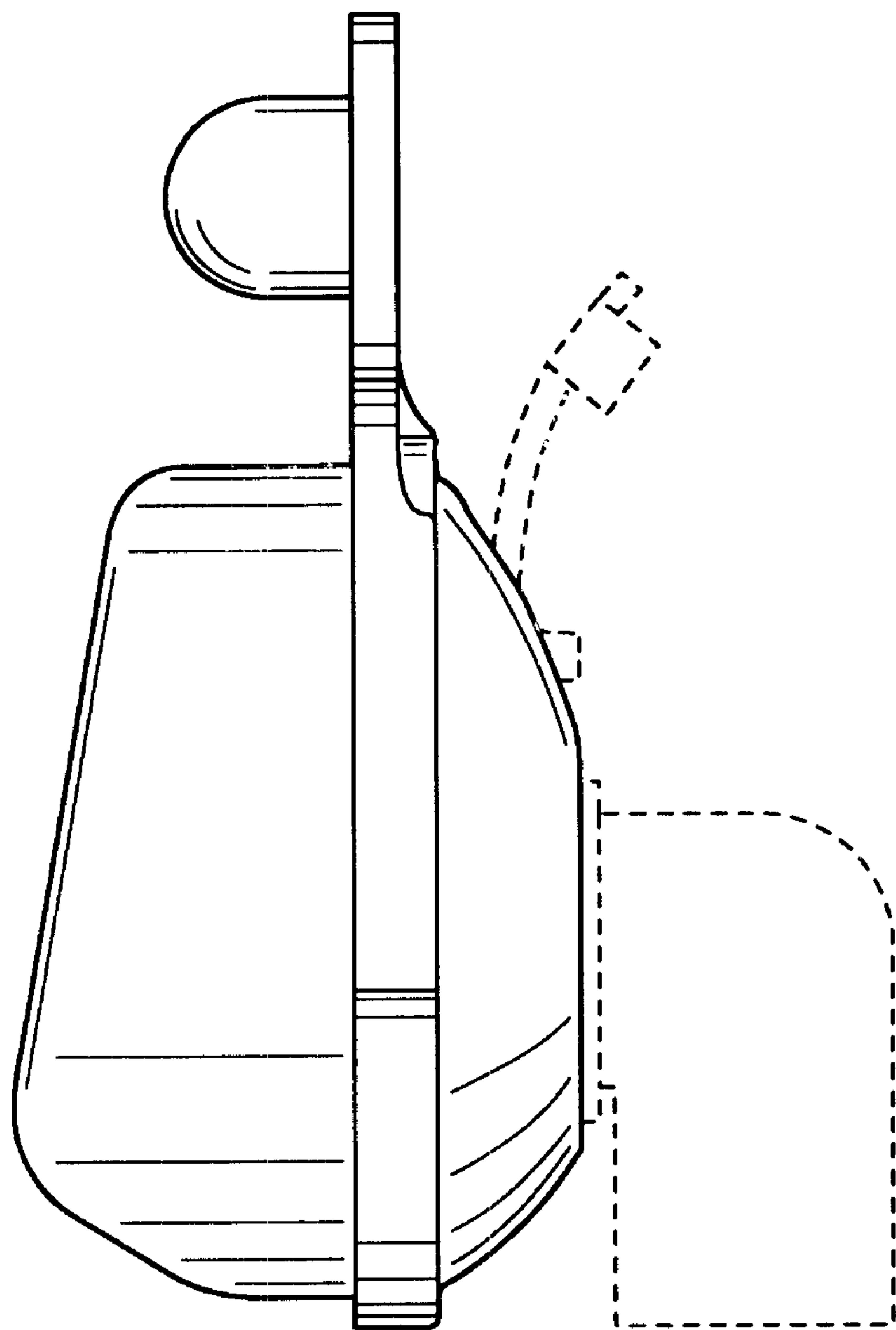


FIG. 4

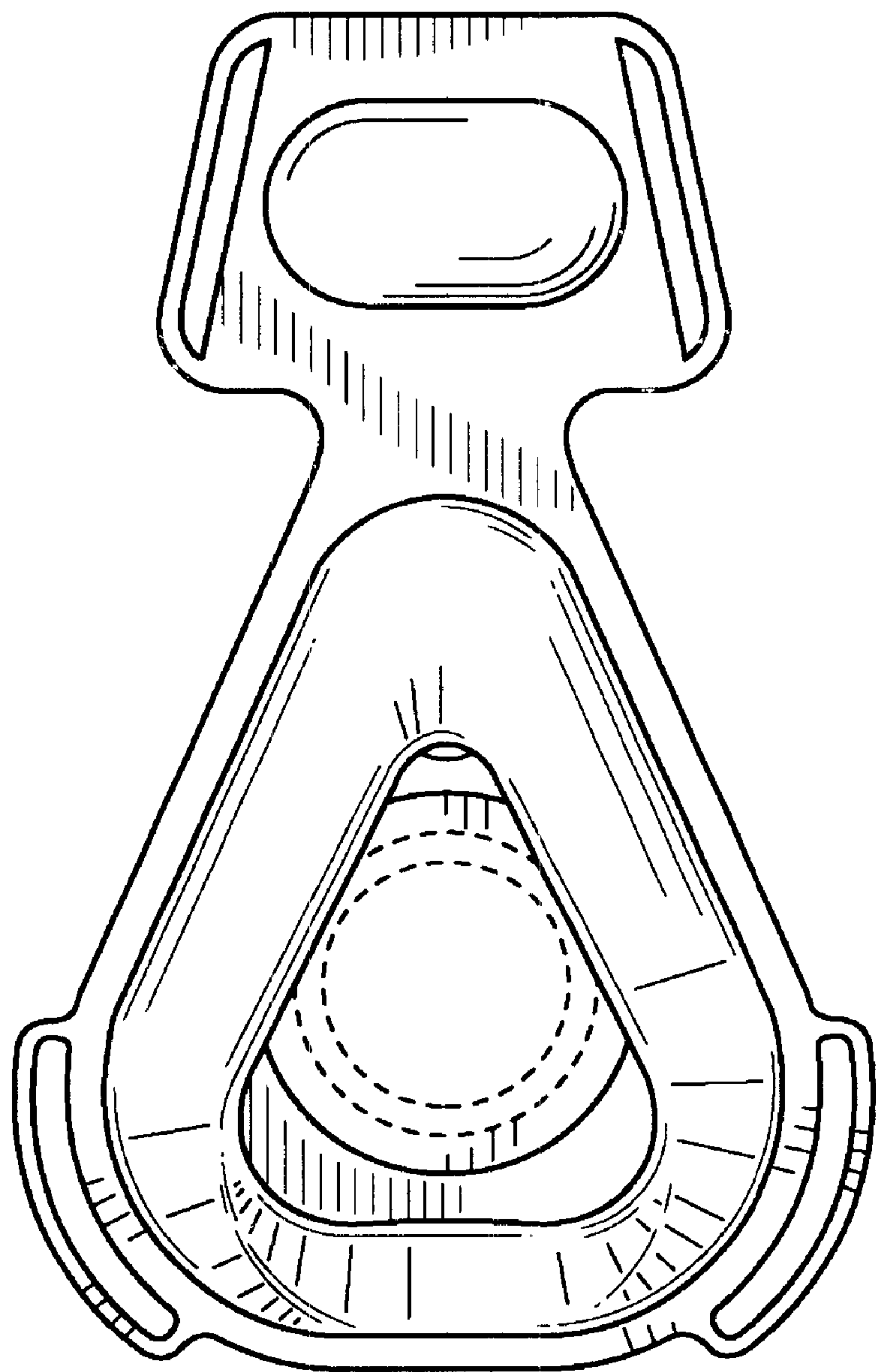


FIG. 5

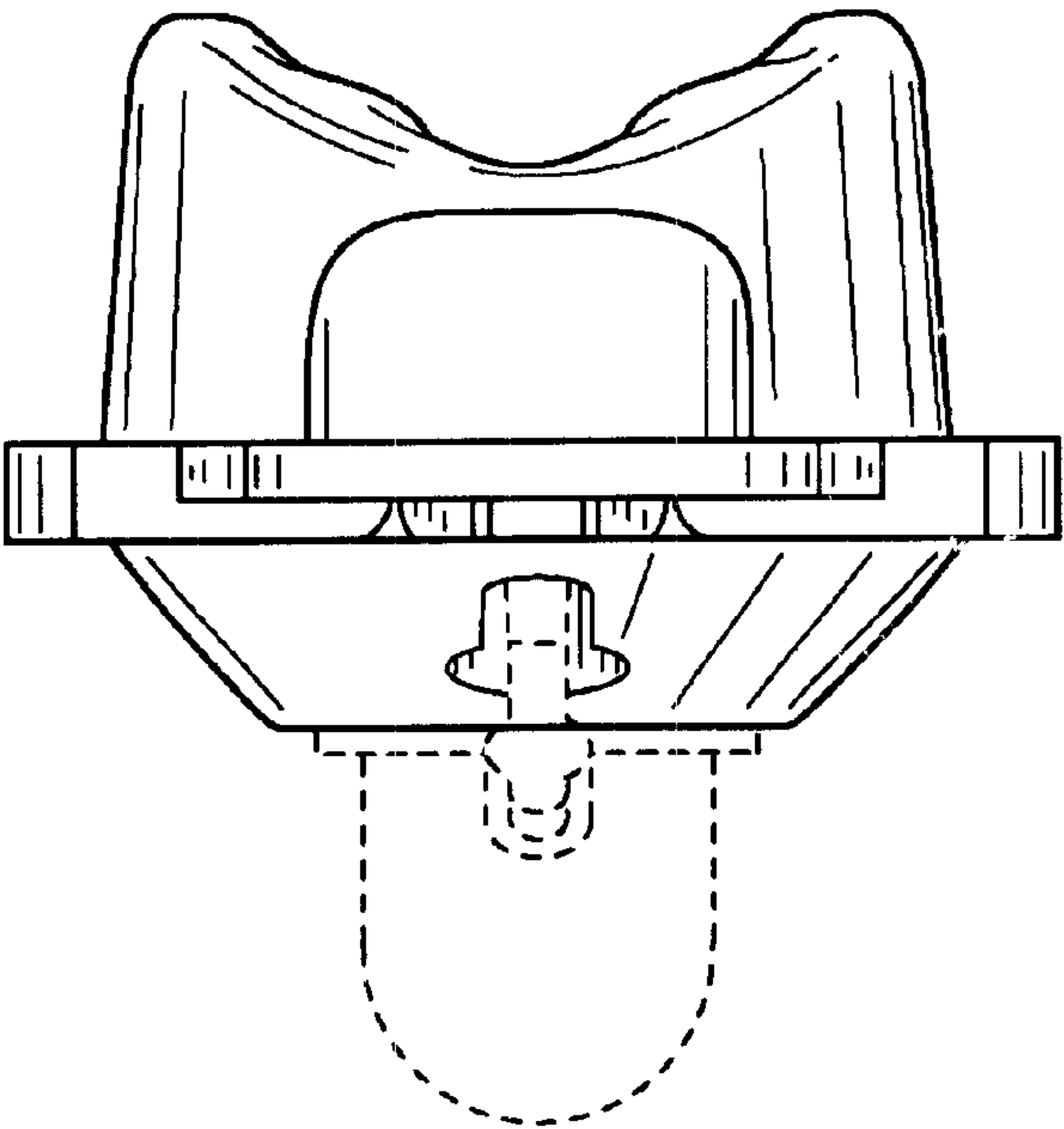


FIG. 6

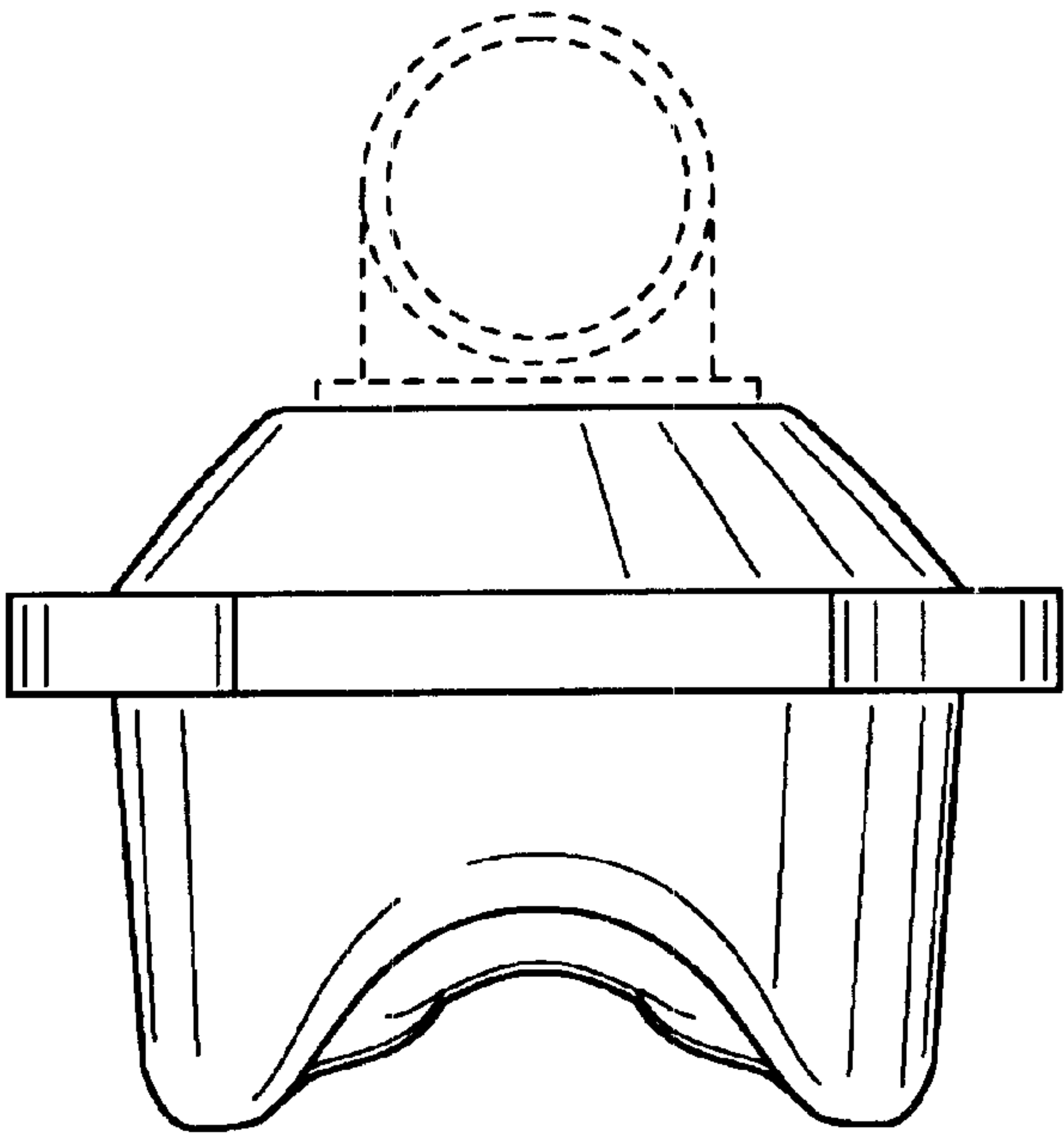


FIG. 7